

IFW

Patent Application No. 10/812,734
Customer Number: 42717

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Shau-Lin Shue, et al.	§	Docket No.:	24061.587
		§		(TSMC2000-0101)
Serial No.:	10/812,734	§		
Filing Date:	March 30, 2004	§	Examiner:	Bradley Smith
		§	Art Unit:	2824
For:	Method for Forming a Self-	§	Conf. No.:	4809
	Passivated Copper Interconnect	§		
	Structure	§		

RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop: Amendment
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed August 31, 2004, applicant hereby elects, Group II, Claims 32-56, which is drawn to a device.

Applicant's election is made with traverse on the grounds that the embodiments delineated by the examiner are not patentably distinct and therefore constitute a single invention concept.

An early action on the merits is respectfully requested.

Respectfully submitted,



David M. O'Dell
Reg. No. 42,044

Date: 9-30-04

HAYNES AND BOONE, LLP
901 Main Street, Suite 3100
Dallas, Texas 75202-3789
Telephone: 972-739-8635
Facsimile: 214-200-0853

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Mail Stop: Amendment, Commissioner For Patents, PO Box 1450, Alexandria, VA 22313-1450 on the date below.

Bonnie Boyle
Name

9-30-04
Date